

FORM PTO-1449

INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

Docket Number (Optional) 82874.0011 Application Number 10/039,838

Applicant

Tallis Y. Chang, et al.

Filing Date

November 6, 2001

Group Art Unit 2874

		U.S. PATEN	T DOCUMENTS	<u> </u>		SU INO DATE IE
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
EK	4,480,184	10-30-1984	Ely		 	
EK	4,860,294	08-22-1989	Winzer, et al.			
			TENT DOCUME	<u></u>		

FOREIGN PATENT DOCUMENTS							
	august 400				Translation		
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	YES	NO
EK	International Search Report for PCT/US02/35439	08-08-2003	PCT		200	•	
	EP 0 331 337 A2	09-06-1989	European		· · · · · · · · · · · · · · · · · · ·	-	
	EP 0 331 338 A2	09-06-1989	European		- G	8 3	
	EP 1 133 082 A1	09-12-2001	European		<u> </u>	ν. <u>.</u> .)
	GB 2 266 160 A	10-20-1993	United Kingdom		CENT	IVE 20	
	DE 43 12 247 A1	10-21-1993	Germany		ER 2	2003 2003	
	DE 29 16 999	11-06-1980	Germany		200	Abstract	
EK	JP 11-84183	03-26-1999	Japan			only	

<u> </u>	The last state of the last sta				
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)					
	Y.P. Li, et al., "Silica-Based Optical Integrated Circuits," IEE Proceeding: Optoelectronics, Institution of Electrical Engineers, Vol. 143, No. 5, pp. 263-280, October 1996.				
	K. Okamoto, et al., "Fabrication of Coherent Optical Transversal Filter Consisting of MMI Splitter/Combiner and Thermo-Optic Amplitude and Phase Controllers," Electronic Letters, Vol. 35, No. 16, pp. 1331-1332, August 5, 1999.				
er	M. Kawachi, "Recent Progress in Silica-Based Planar Lightwave Circuits on Silicon," IEE Proceedings: Optoelectronics, Institution of Electrical Engineers, Vol. 143, No. 5, pp. 257-262, October 1996.				

EXAMINER	Ellen	Krm	DATE CONSIDERED	2/4/04
	- MED			

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.